

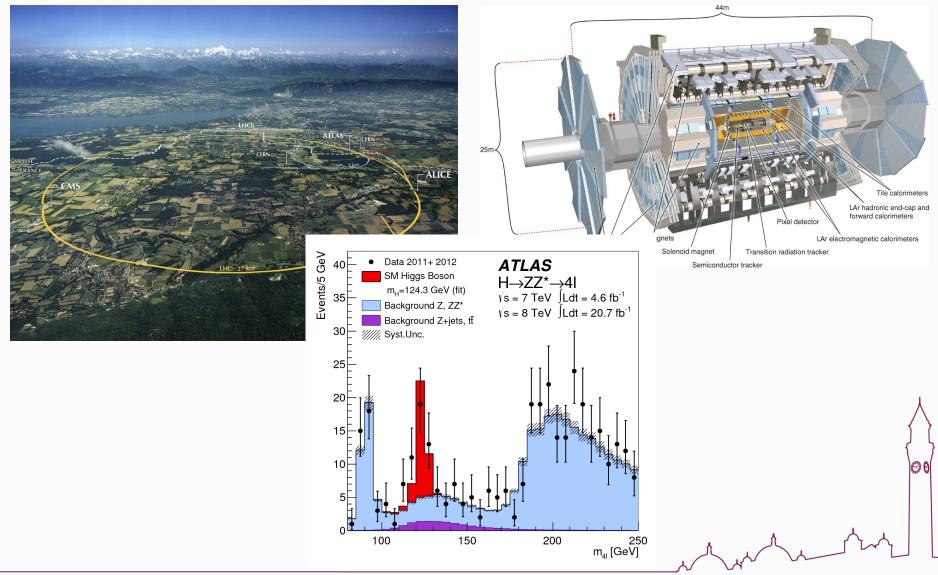
The ATLAS Inner Tracker detector for the High-Luminosity LHC upgrade

Laura Gonella 4 July 2018

Outline

- The HL-LHC upgrade & challenges for detectors
- The ATLAS Inner Tracker (ITk) design and performance
- ITk detector modules
 - Sensor development
 - Readout electronics design
- Lightweight services
- ITk production
- Conclusion

LHC and ATLAS



The High-Luminosity LHC

CERN Accelerating science



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by Corinne Pralavorio

Posted by Corinne Pralavorio on 26 Jun 2018. Last updated 26 Jun 2018, 16.21. Voir en français



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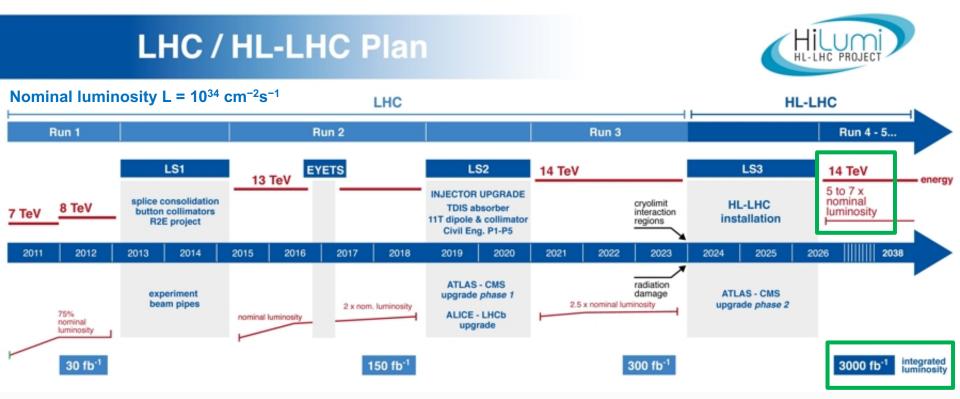
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The High-Luminosity LHC

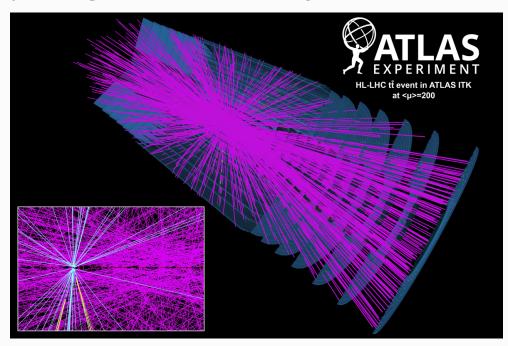


- Higher energy and luminosity benefit searches for new particles, precision measurements and study of rare processes but pose severe challenges to the detectors
- The vertex and tracking detectors, being the closest to the IP, will need significant upgrade

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Particle density and data rate

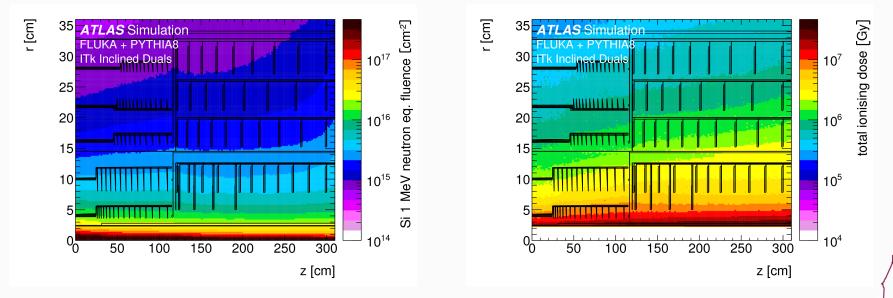
With an instantaneous peak luminosity up to 7.5 x 10³⁴ cm⁻²s⁻¹ the mean number of interactions per bunch crossing (i.e. every 25 ns) is 200 (pile-up) → high particle density and data rate



 Finely segmented detectors and fast readout electronics are needed to keep low hit occupancy [hits/cm²/sec]

Radiation levels

- The integrated luminosity of 4000 fb⁻¹ results in x10 radiation damage with respect to LHC
 - Fluence up to 1.3 x 10¹⁶ 1 MeV n_{eq}/cm^2
 - Total Ionising Dose up to 10MGy = 1 Grad

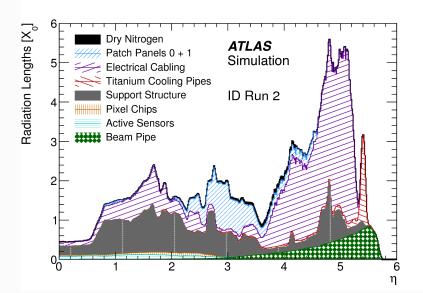


Radiation hard technologies for sensor and electronics

More challenges

Material budget

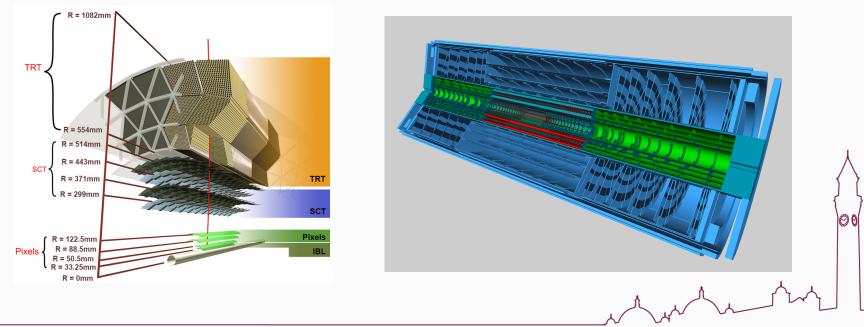
- Multiple scattering and nuclear interactions in tracker material limit tracker and calorimeter performance
- Dominant source of material are services and support structures



- Hermeticity and sufficient number of hits over large angular acceptance
 - Particles originating from within the 30cm-long beam spot should hit a sensor in each layer they traverse
 - A high number of hits is needed for good tracking efficiency but a tradeoff with the amount of material has to be found
- Cost should be minimised
- All these challenges have to be met while keeping the same tracking performance of the current ATLAS tracking detector

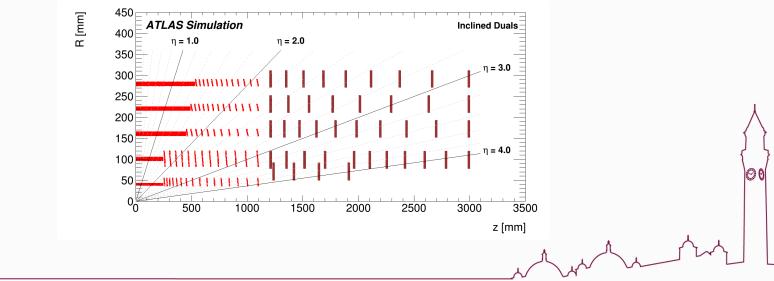
ATLAS tracker upgrade

- The current ATLAS Inner Detector (ID) needs to be replaced for the HL-LHC
 - Severe radiation damage to all components
 - TRT technology cannot cope with hit occupancy
- ATLAS is planning a new all-silicon Inner Tracker (ITk) using state-of-the-art silicon technologies and optimised design of all detector components



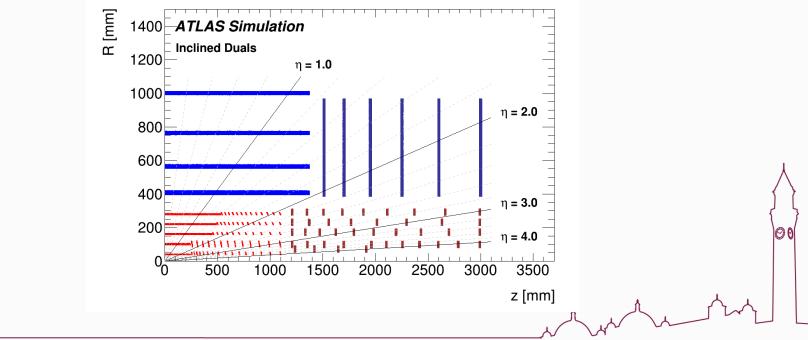
ITk layout

- Pixel detector
 - Cover to $\eta = 4.0$
 - 13 m² of silicon sensors
 - Design optimised to **improve hit coverage with less material**
 - Inclined modules
 - Endcap-ring system
 - Two innermost layers designed to be replaceable to cope with radiation environment



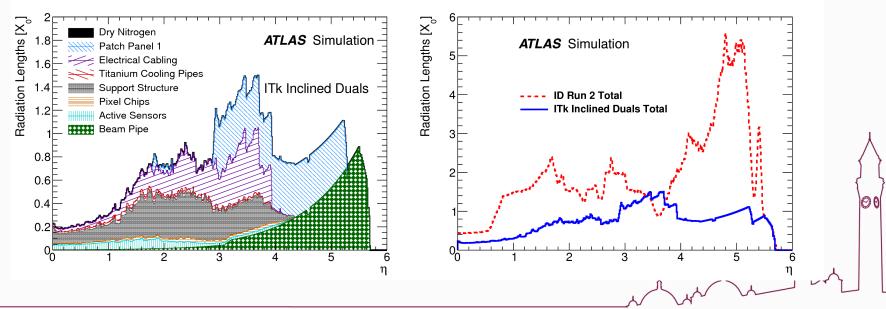
ITk layout

- Strip detector
 - Cover to $\eta = 2.7$
 - 165 m² of silicon sensors
 - 4 barrel layers and 6 endcap
 - Modules loaded on both side of support structure with small stereo angle giving the second coordinate measurement



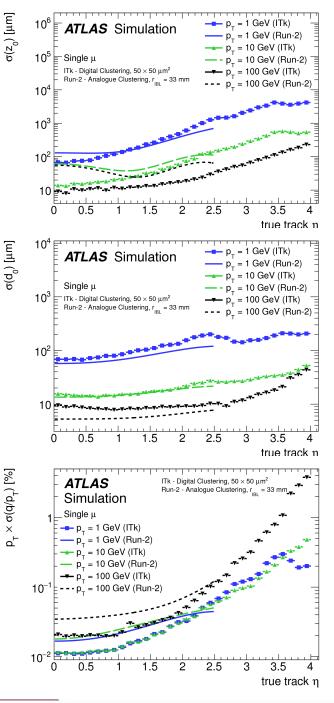
ITk material budget

- The material of the ITk is significantly less than for the ID at almost all η
- The main drivers for the improvement are
 - Thinner silicon
 - Innovative power distribution schemes
 - Optimized routing of services
 - Rigid mechanical structure with lightweight carbon foam core



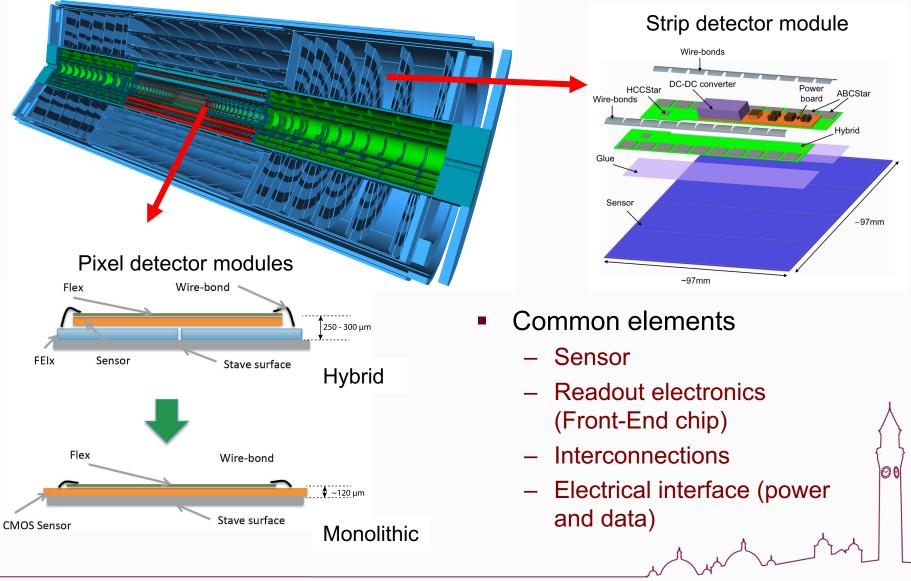
ITk track parameters resolution

- Longitudinal impact parameter resolution (pile-up rejection)
 - Improved by pixel finer segmentation in z (50 μm instead of 250 μm)
- Transverse impact parameter resolution (btagging)
 - Worse resolution at high p_T due to larger radius of inner pixel layer (39mm instead of 33.5mm; radiation and data rate prohibitive at smaller radii)
- Transverse momentum resolution
 - Improved by almost a factor 2 thanks for the higher precision of the strip detector wrt. TRT
- Lower material benefits all track parameters resolution



ITk detector modules

Silicon detector technologies for the ITk



Developed for operation at the LHC

Hybrid pixel detector concept

Flex

Baseline concept for ITk pixel detector

Sensor

Optimised sensor design

FEIx

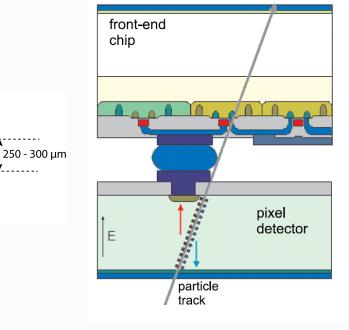
- New CMOS technology for the readout chip
- Sensor and readout electronics are separate entities connected via fine pitch bump bonds

Stave surface

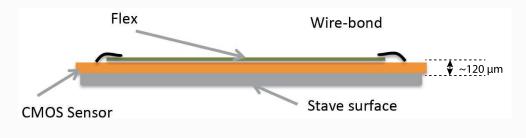
Each pixel is connected to one readout channel in the FE chip

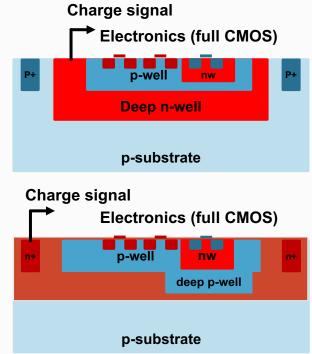
Wire-bond

- Expensive, non-commercial hybridization process
- Electrical interface, **flex**, glued on sensor backside
 - Hosts passive components and auxiliary chips (i.e. for data aggregation and transmission)
 - Wire bonds connection to sensor and FE chip



DMAPS in commercial CMOS technology

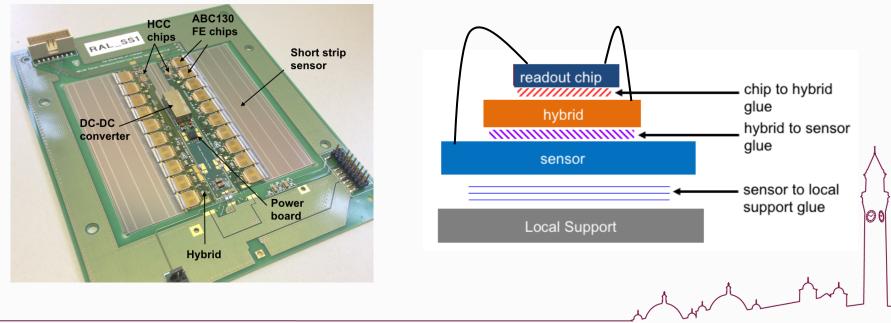




- Monolithic active pixels sensors (MAPS)
 - Sensor and readout electronics in the same substrate
 - Originally developed for low rate applications (STAR and ALICE ITS)
- Recent development with commercial CMOS technologies improve radiation-hardness and high rate capability → Depleted MAPS
- No hybridisation and advantages of commercial fabrication process
 → low cost and ease of construction
- Candidate technology for pixel outermost layer

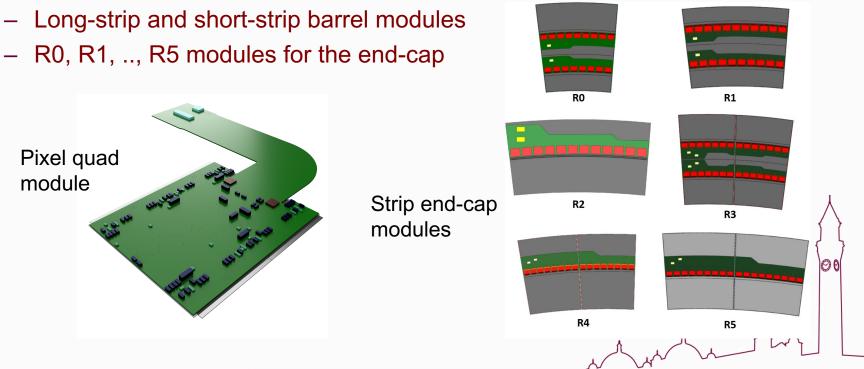
Strip detector module

- Hybrid concept with separated sensor and readout electronics
- Two electrical interfaces, hybrid flex and power board, glued on the sensor front-side
- Readout ASICs and data aggregator chip are glued on the hybrid flex and wire bonded to the sensor
 - Each strip is connected to one readout channel in the FE chip
- Power distribution is provided via the power board



Module types in the ITk

- To provide hermetic coverage, different module configurations are need resulting in a large number of different sensors and hybrid/flex flavours
- Pixel modules can be single, dual, or quad depending on whether the sensor is bump bonded to one, two, or four FE chips
- Strips



Sensor development

Radiation tolerant silicon sensors

- High energy particles introduce complex lattice defects in the silicon bulk, i.e. energy levels in the silicon band gap
- Increased leakage current
 - Shot noise
 - Temperature increase → higher leakage current → need to cool sensors to avoid thermal runaway
- Change in effective doping concentration
 - Change in charge collection volume
- Charge trapping
 - Smaller sensor signal

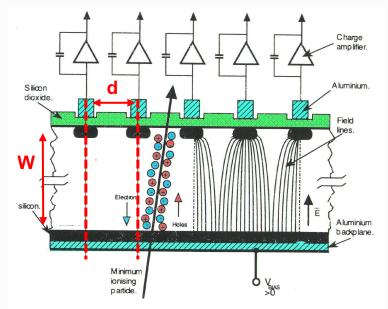
	Max fluence [1 MeV n _{eq} /cm ²]
Pixel	1.3 x 10 ¹⁶
Strip	1.2 x 10 ¹⁵

To mitigate these effects charge should be collected by drift

Drift based silicon sensors

- Drift based silicon sensors work as a reverse biased pn-junction
- Low doped, i.e. high resistivity, silicon bulk with highly doped collection electrodes
 - The segmentation (pitch, d) of the contacts defines the **spatial resolution** (σ)
- High (reverse) bias voltage (V_{bias})
 - Depletion grows into the substrate
 - Electric field
- Traversing charged particles create e-/h+ pairs
- Movement of charges (i.e. drift in electric field) towards the electrodes generates a signal
 - Large collected charge, fast charge collection, radiation-hard

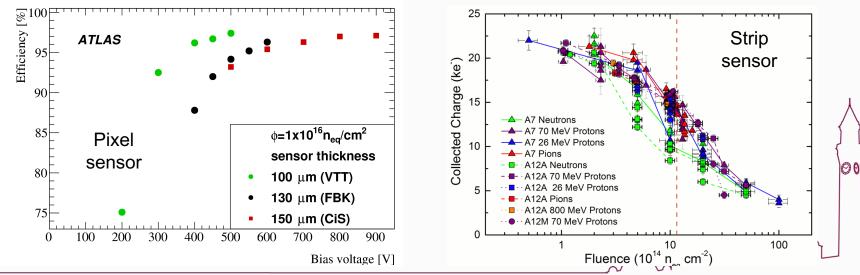
Cross section of a silicon sensor



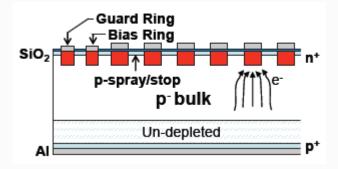


Planar pixel and strip sensors

- **n-in-p** configuration for both strips and pixels
 - In the ID strips are p-in-n and pixels n-in-n
 - Signal from electrons faster than holes
 - One sided process, simpler and cheaper than n-in-n
- Optimised design of bias structure and edge region to obtain uniform electric field
- Pixel pitch 50 x 50 or 25 x 250 μm², thickness 100-150 μm
- Strip pitch 75 μm x 25-50 mm, thickness 300-320 μm



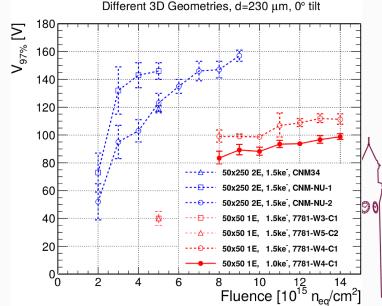


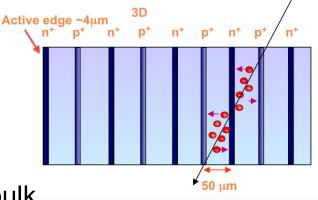


3D sensors

- Alternative geometry for pixel sensors that provides higher radiation tolerance by design: drift path decoupled from particle path
 - First application in the IBL detector
- Electrodes penetrate vertically in the sensor bulk
 - Shorter charge collection distance \rightarrow less charge trapping
 - **High field with low voltage** \rightarrow lower power, i.e. heat, after irradiation
- Technology of choice for pixel inner layer

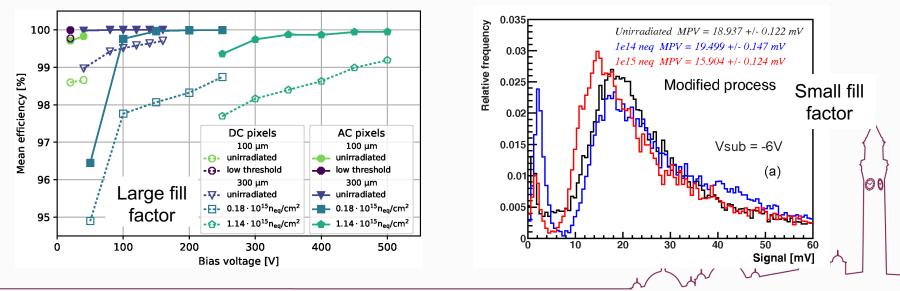
	IBL	HL-LHC	
Pixel size [µm ²]	50 x 250	50 x 50	25 x 100
Electrode config	2E	1E	2E
Electrode spacing [µm]	67	35	27
Thickness [µm]	230	230	
Rad-hard [1MeV n _{eq} /cm ²]	9 x 10 ¹⁵	1.4 x 10 ¹⁵	





CMOS sensors

- Recently commercial CMOS technologies have become available with HV capability on HR substrate
 - Imaging sensors market
- CMOS sensors investigated as a possible replacement of traditional silicon sensors for hybrid pixels or to develop DMAPS detectors for the pixel outmost layer
 - Significant advantages in terms of cost and large area production
 - Demonstrated adequate radiation tolerance



Readout electronics design

Readout electronics

- Basic functionality
 - The signal from pixel and strip sensors is integrated, amplified and digitized by the FE chip
 - The FE chips stores the hit information and sends it to the detector data acquisition system upon arrival of the trigger signal
 - Different readout architectures are developed based on the rate and radiation levels
- To cope with the high hit rate, fast readout with high logic density (i.e. memory) is needed
- Smaller feature size CMOS technologies are used for the ITk
 - 65 nm CMOS for the pixel FE (130 and 250 nm in ID pixel)
 - 130 nm CMOS for the strip FE (250 nm in ID strip)

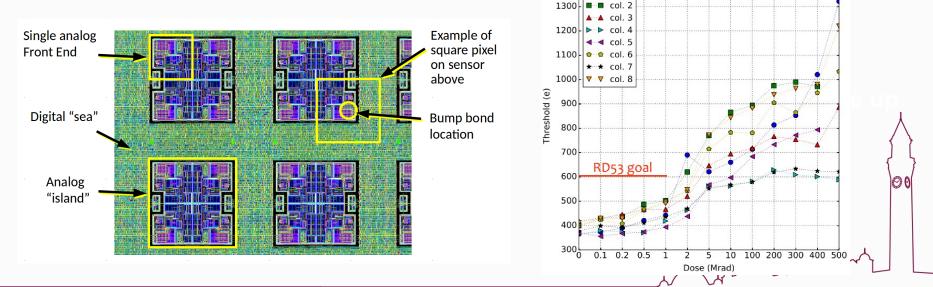
Radiation hardness of CMOS technologies

- Total ionising dose effects
 - Charge trapping in thick isolation oxides and at the oxide-silicon interfaces lead to degradation of the performance of MOSFETs transistors
 - Dependent on dose rate and temperature history of the FE (annealing)
- Single Event Effects, **SEE**
 - Local ionisation effects that change the status of memory cells
- Deep submicron CMOS technologies provide adequate radiation tolerance provided mitigation strategies are put in place
 - Pixel innermost layers will be replaced after 2000 fb⁻¹
 - Strip detector operational T profile devised to reduce the effects of TID
 - Triplicated logic and reset schemes to protect against SEE

	TID [Mrad]	
Pixel	10 ³	
Strip	50	

Readout for HL-LHC innermost layers

- Very innovative design based on a new readout architecture
- Analog "islands" in a digital synthesized "sea"
- Collection of large digital cores containing many regions
 - Complex functionality in the pixel matrix
 - Resources shared among many pixels
- 2 dimensional digital connectivity
- Smart clustering in the pixel matrix to send most information with least bandwidth (5.12 Gbps/chip)

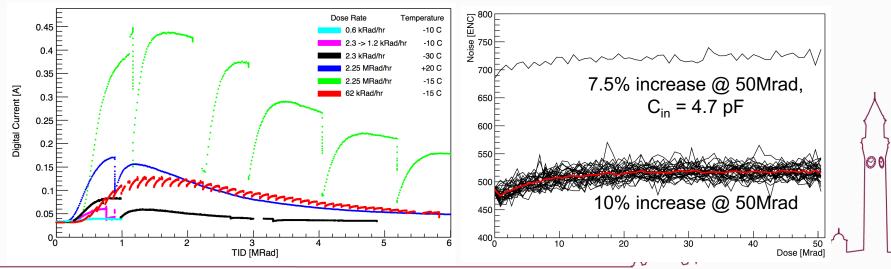


Strip FE readout chip: ABCStar

- 256 readout channels with binary readout
- Design compatible with multi-level trigger scheme (increased buffering per channel)
 - Single Level- 0 trigger (L0) at 1 MHz with a maximum latency of 10 μ s
 - L0-L1 trigger: information from ITk used as input for a second level L1 trigger signal combined with calo and muon data
 - L0 readout at 1 MHz for 10% of the modules belonging to the Region of Interest (RoI) identified at L0, followed by full read-out at L1 at 400 kHz
- LCB protocol
 - L0, commands, and bunch crossing ID sent in one encoded data stream designed to allow triggering on 4 consecutive bunch crossings
- L0 tag
 - The L0ID is generated by the DAQ and attached as a tag to the L0
 - Modules receive the L0ID and send back data with this identifier
 - Errors affect only one frame (i.e. 4 triggers)
 - No need for synchronized counters in chip and DAQ

Strip FE TID characterization

- Low temperature, low dose rate irradiations show a current evolution with TID compatible with the radiation induced narrow channel effect typical of 130 nm CMOS technology node
 - Current increase due to positive charge trapped in the later STI
 - Current decrease due to later built-up of negative interface states
 - Effect well characterised, model available to predict current peak at different T and dose rate
- FE noise increase with TID mitigated by the use of enclosed layout transistors



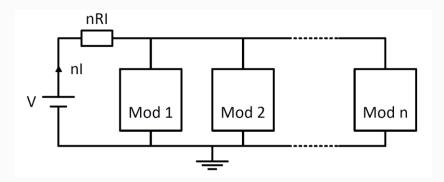
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Lightweight services

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Power distribution

 Tracking detectors for high rate environments are power hungry devices → high current consumption



- Traditional tracking detectors power distribution scheme
 - Each module is powered independently with a constant voltage
 - High number of long cables with large cross section
 - At the LHC cable channels are saturated, services dominate the material budget, power efficiency is below 50%
- Readout electronics design for the HL-LHC optimises power consumption against rate requirements but given the larger number of detector channels, the power consumption will be higher than then ID → New powering schemes are needed to reduce the transmitted current
 - Serial powering for the pixel detector
 - DC-DC conversion for the strip detector

Serial powering for pixels

- Current based powering scheme
 - N nodules are powered in series by a constant current = current for one module
 - Voltages are generated by regulators on-chip
- Wrt. a conventional voltage based powering scheme the transmitted current scales of a factor N: I → I/N
 - Smaller cable cross section
 - Reduced power losses on the cables
- Number of modules in the chain is a trade-off between redundancy, quality of data transmission, and amount of cables
- Dedicated developments
 - Integrated regulator to convert input current to stable voltage for FE chips, Shunt-LDO
 - Bypass chip to disconnect faulty modules from the chain
 - Both need to meet the radiation requirements

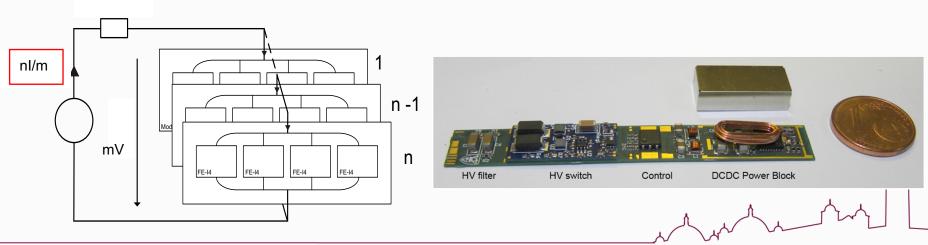


RI Regulator Mod n nV Regulator Mod 2 Regulator Mod 1

DC-DC conversion

nRI/m

- Power transmitted at high voltage and low current to the modules
- x2 DC-DC buck converter on module
 - Radiation-hard tolerant converter development by CERN PH-ESE group
- Optimised integration of regulator and coil on power board to shield module from EMI
 - Solenoidal flat coil geometry to fit into available space
 - Shield made of a mix of aluminium and copper
 - Demonstrated electric and magnetic fields shielding whilst still maintaining a target efficiency of 75% at the nominal load of 2 A



ITk production

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Production of a 200m² silicon tracker

- The production of the ATLAS ITk is a challenge as much as the R&D to identify the right technologies and design for the components
- Quality control and quality assurance
 - Assure component reliability in extreme experimental conditions
 - Monitor rate and quality of production to detect problems that may arise and stop production
- Industrialised production flow
 - Common tooling development and assembly procedures
- Database
 - Store information from all detector elements QC and QA during production
 - Track the geographic location and utilisation of all parts during construction
 - Debugging of faulty conditions during operation

Conclusion

- To benefit from the physical potential of the HL-LHC the ATLAS experiment is preparing the replacement of its inner tracking system
- The new, all-silicon Inner Tracker (ITk) maintains and in some cases improves the tracking performance of the ATLAS detector while coping with 200 pile-up events per collision
- Radiation tolerant sensor and readout electronics prototypes have demonstrated the required functionality
- Production is due to start in 2020 for the strip detector and in 2021 for the pixel detector. The 200m² ITk detector will be produced in three years.